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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/775,854	02/10/2004	Urs Bapst	YOR920030633US1	1076	
7590 08/24/2005			EXAMINER		
Ryan, Mason & Lewis, LLP Suite 205			BLEVINS,	BLEVINS, JERRY M	
1300 Post Road			ART UNIT	PAPER NUMBER	
Fairfield, CT 06824			2883		
			DATE MAILED: 08/24/2003	5	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
•	10/775,854	BAPST ET AL.			
Office Action Summary	Examiner	Art Unit			
	Jerry Martin Blevins	2883			
The MAILING DATE of this communication ap					
Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply bly within the statutory minimum of thirty (3) will apply and will expire SIX (6) MONTHS e, cause the application to become ABANI	by be timely filed 0) days will be considered timely. S from the mailing date of this communication. DONED (35 U.S.C. 8 133)			
Status		•			
1) Responsive to communication(s) filed on 10 F	ebruary 2004.				
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closed in accordance with the practice under	Ex parte Quayle, 1935 C.D. 1	1, 453 O.G. 213.			
Disposition of Claims					
4)⊠ Claim(s) <u>1-23</u> is/are pending in the application	1.				
4a) Of the above claim(s) is/are withdra					
5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1-24</u> is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/o	or election requirement.				
Application Papers					
9) The specification is objected to by the Examine	er.				
10)⊠ The drawing(s) filed on 10 February 2004 is/ar		ected to by the Examiner.			
Applicant may not request that any objection to the	· · · · · · · · · · · · · · · · · · ·	•			
Replacement drawing sheet(s) including the correct					
11) The oath or declaration is objected to by the E	- · · · · - · · · · · · · · · · · · · ·				
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign	n priority under 35 U.S.C. § 11	19(a)-(d) or (f).			
a) ☐ All b) ☐ Some * c) ☐ None of:					
1. Certified copies of the priority documen	ts have been received.	·			
2. Certified copies of the priority documen	•	lication No			
3. Copies of the certified copies of the price	ority documents have been re	ceived in this National Stage			
application from the International Burea	au (PCT Rule 17.2(a)).				
* See the attached detailed Office action for a list	t of the certified copies not rec	ceived.			
Attachment(s)	_				
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) 		nmary (PTO-413) Nail Date			
 2) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 		mal Patent Application (PTO-152)			
Paper No(s)/Mail Date <u>02/10/2004</u> .	6) Other:	-			

Art Unit: 2883

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-6, 10, 11, 14-19, and 21-23 are rejected under 35 U.S.C. 102(e) as being anticipated by US Patent to Kuhmann et al., number 6,832,013.

Regarding claim 1, Kuhmann teaches a method of processing a circuit board (Figure 5, element 10) having one or more optical waveguides (18) associated therewith, the method comprising the steps of: providing one or more etch stop layer (14) in proximity to the one or more waveguides, at least one of the etch stop layers comprising one or more fiducials (19) therein; and from a surface of the circuit board, using the one or more etch stop layers to selectively remove material to provide openings having a defined positioning and depth in the circuit board (column 7, lines 8-24).

Regarding claim 21, Kuhmann teaches a circuit board (Figure 5, element 10) having one or more optical waveguides (18) associated therewith, comprising one or more openings (column 7, lines 8-24) each with a positioning and depth defined using

Art Unit: 2883

one or more etch stop layers (14) in proximity to the one or more waveguides, at least one of the etch stop layers comprising one or more fiducials (19) therein.

Regarding claims 2 and 22, Kuhmann teaches the limitations of the base claims 1 and 21, respectively. Kuhmann also teaches that the one or more fiducials define a positioning in a plane of the circuit board (abstract).

Regarding claims 3 and 23, Kuhmann teaches the limitations of the base claims 1 and 21, respectively. Kuhmann also teaches that the one or etch stop layers define a depth in the circuit board (column 7, lines 25-30).

Regarding claim 4, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches at least one of the openings exposes at least a portion of the one or more waveguides (column 7, lines 31-35).

Regarding claim 5, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches that the one or more etch stop layers acts as a selective etch stop (column 7, lines 8-24).

Regarding claim 6, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches that the one or more etch stop layers acts as a complete etch stop (column 7, lines 25-30).

Regarding claim 10, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches the material removed comprises a substrate material (column 7, lines 31-35).

Regarding claim 11, Kuhmann teaches the limitations of the base claim 10.

Kuhmann also teaches that the substrate is organic material (column 14, lines 40-54).

Art Unit: 2883

Regarding claim 14, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches at least a portion of the material is selectively removed using reactive ion etching (column 7, lines 31-35).

Regarding claim 15, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches one or more of the openings serve as one or more reference points to align at least one optical component (Figure 19, element 25) with one or more waveguides (Figure 19, element 18).

Regarding claims 16 and 17, Kuhmann teaches the limitations of the base claim 15. Kuhmann also teaches that the at least one optical component comprises one or more alignment pins (Figures 19, element 48) each having a shape that corresponds with one or more of the openings, wherein the alignment pins are circular.

Regarding claim 18, Kuhmann teaches the limitations of the base claim 15. Kuhmann also teaches that the at least one optical component is an opto-electronic module (column 15, lines 49-57).

Regarding claim 19, Kuhmann teaches the limitations of the base claim 1.

Kuhmann also teaches that the one or more openings serve as one or more reference points to align at least one receptacle for an optical component with one or more waveguides (column 15, lines 49-57).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

Art Unit: 2883

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 7 and 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kuhmann in view of US Patent to Chan et al., number 5,122,852.

Regarding claims 7 and 8, Kuhmann teaches the limitations of the base claim 1. Kuhmann does not teach that one or more of the etch stop layers comprises a metal. Chan teaches etch stop layers comprising gold. It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Kuhmann with the gold etch stop layers of Chan. The motivation would have been to improve the precision of the etching.

Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over Kuhmann in view of US Pre Grant Publication to Burns, number 2001/0046346.

Regarding claim 9, Kuhmann teaches the limitations of the base claim 1.

Kuhmann does not teach that one or more of the etch stop layers comprises a reflective dielectric thin film. Burns teaches etch stop layers comprising a reflective dielectric thin film (page 7, paragraph 81). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Kuhmann with the reflective dielectric thin film etch stop layers of Burns. The motivation would have been to improve the precision of the etching.

Claim 12 is rejected under 35 U.S.C. 103(a) as being unpatentable over US Pre Grant Publication to Burdick, Jr. et al., number 2002/0075107.

Art Unit: 2883

Regarding claim 12, Kuhmann teaches the limitations of the base claim 1. Kuhmann does not teach that the material is selectively removed user laser ablation techniques. Burdick teaches removing material using laser ablation techniques (page 3, paragraph 26). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Kuhmann with the laser ablation techniques of Burdick. The motivation would have been to improve the accuracy of the removal.

Claim 13 is rejected under 35 U.S.C. 103(a) as being unpatentable over Kuhmann in view of Burdick as applied to claim 12 above, and further in view of US Patent to Coyle, Jr. et al., number 5,101,090.

Regarding claim 13, Kuhmann in view of Burdick teaches the limitations of the base claim 12. Kuhmann in view of Burdick does not teach that the laser ablation techniques comprise use of a carbon dioxide laser. Coyle teaches the use of a carbon dioxide laser for laser ablation techniques (column 5, lines 10-22). It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Kuhmann in view of Burdick with the use of the carbon dioxide laser of Coyle. The motivation would have been to improve the accuracy of the removal.

Claim 20 is rejected under 35 U.S.C. 103(a) as being unpatentable over Kuhmann.

Regarding claim 20, Kuhmann teaches the limitations of the base claim 1.

Kuhmann does not teach that the circuit board has two or more waveguides associated therewith. It would have been obvious to one of ordinary skill in the art at the time of the invention to include two or more waveguides in the circuit board since it has been held

Art Unit: 2883

Page 7

that mere duplication of the essential working parts of a device involves only routine skill in the art, St. Regis Paper Co. v. Bemis Co., 193 USPQ 8. The motivation would have been to improve the efficiency of the alignment.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jerry Martin Blevins whose telephone number is 571-272-8581. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Frank G. Font can be reached on 571-272-2415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

JMB

Frank G. Font Supervisory Patent Examiner Technology Center 2800

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